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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of

Daniel R. NEAL et al. : Group Art Unit: TBD

Serial No. NEW : Examiner: TBD

Filed: 21 April 2004 :

For: SYSTEM AND METHOD OF MEASURING AND MAPPING THREE

DIMENSIONAL STRUCTURES

INFORMATION DISCLOSURE STATEMENT
(SUBMISSION WITH CONTINUATION-IN-PART OR
RULE 1.53(b) CONTINUATION OR DIVISIONAL APPLICATION)

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Sir:

Pursuant to 37 C.F.R. §§ 1.97 and 1.98, applicant(s) hereby submit(s) an Information Disclosure Statement for consideration by the Examiner.

I. LIST OF PATENTS, PUBLICATIONS OR OTHER INFORMATION

The patents, publications or other information submitted for consideration by the Office are listed on PTO-1449 form(s), attached hereto.

II. REFERENCES PREVIOUSLY CITED OR SUBMITTED

Pursuant to 37 C.F.R. § 1.98(d), consideration of information listed on the PTO-1449 form(s) is requested since any patents, publications or other information which are listed on the PTO-1449 form(s) but for which copies are not enclosed herewith, were previously cited by or submitted to the PTO in one of the following applications which has been relied upon for an earlier filing date under 35 U.S.C. § 120:

U.S. Serial Number	U.S. Filing Date			
10/419,072	21 April 2003			
09/692,483	20 October 2000			
10/369.513	21 February 2003			

III. <u>FEES</u>

This Information Disclosure Statement is being filed concurrent with the filing of a continuation-in-part, continuation or divisional patent application; therefore, no fee is required.

If the Examiner has any questions concerning this IDS or requires a copy of any of the references cited but not provided, he/she is requested to contact the undersigned. If it is determined that this IDS has been filed under the wrong rule, the PTO is requested to consider this IDS under the proper rule (with a petition if necessary) and charge the appropriate fee to Deposit Account No. 50-0238.

If necessary, the Commissioner is hereby authorized in this, concurrent, and future replies, to charge payment or credit any overpayment to Deposit Account No. 50-0238 for any additional fee required under 37 C.F.R. §§ 1.16 or 1.17; particularly, extension of time fees.

Respectfully submitted,

VOLENTINE FRANCOS, P.L.L.C.

Kenneth D. Springer Reg. No. 39,843

12200 Sunrise Valley Drive, Suite 150 Reston, VA 20191 Tel. No. (703) 715-0870 Fax No. (703) 715-0877

Dated: 21 April 2004

Docket Number (Optional) Application Number WFS.006 CIP NEW INFORMATION DISCLOSURE CITATION Applicant(s) e san participation of the company of Daniel R. NEAL et al. (Use several sheets if necessary) Filing Date Group Art Unit 21 April 2004 TBD U.S. PATENT DOCUMENTS EXAMINER REF DOCUMENT NUMBER DATE FILING DATE NAME CLASS SUBCLASS INITIAL IF APPROPRIATE 6,199,986 03/13/2001 Williams et al. В 6,299,311 B1 10/09/2001 Williams et al. c 4,725,138 02/16/1988 Wirth et al. D 5,978,053 11/02/1999 Giles et al. 6,095,651 E 11/01/2000 Williams et al. 6,270,221 B1 08/07/2001 Liang et al. G 5,258,791 11/02/1993 Penney et al. Н 4,021,102 05/03/1977 Iizuka 3,819,256 06/25/1974 Bellows et al. 5,929,970 07/27/1999 Mihashi ĸ 6,271,915 B1 08/07/2001 Frey et al. FOREIGN PATENT DOCUMENTS REF DOCUMENT NUMBER DATE Translation COUNTRY CLASS SUBCLASS YES NO 0 625 332 A2 11/23/1994 **European Patent Office** M DE 42 22 395 A1 01/13/1994 Germany 0 373 788 A2 06/20/1990 **European Patent Office** n WO 83/02716 08/18/1983 **PCT** WO 01/89372 A2 11/29/2001 PCT OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.) Q Geary, Joseph M., Introduction to Wavefront Sensors, SPIE Press, Vol. TT18, copyright 1995, pages 93-95.

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